## DECLARATION, POWER OF ATTORNEY AND CORRESPONDENCE ADDRESS

Applicants:	MACRONIX INTERNATIONAL CO., LTD.
Title:	A MASK FOR REDUCING PROXIMITY EFFECT
Seyfarth Shaw Matter No.:	

As below named inventors, we hereby declare that:

Our residence, post office address and citizenship are as stated below next to our names.

We believe we are the original, first, and joint inventors of the subject matter which is claimed and for which a patent is sought on the invention described and claimed in the above-captioned application.

We have reviewed and understand the contents of the above captioned application, including the claims.

We acknowledge the duty to disclose information which is material to the patentability of the claims in this application in accordance with 37 CFR §1.56(a).

A request for foreign priority is made pursuant to 37 CFR §1.55 based on the following foreign application:

[Application No.]		
[Country]		
[Filing Date]	, <u> </u>	<u>u.</u>

There is no foreign application having a filing date before that of the application on which priority is claimed.

On behalf of our assignee, and not on our own behalf, we appoint Seyfarth Shaw, and members and associates thereof including Harold V. Stotland (Reg. No. 24,492), Alan L. Unikel (Reg. No. 24,142), J. Terry Stratman (Reg. No. 25,165) George H. Gerstman (Reg. No. 22,419), Garrettson Ellis (Reg. No. 22,792), David L. Newman (Reg. No. 37,196) and William J. Hallihan (Reg. No. 39,210), as attorneys, with full power of substitution and revocation to

prosecute this application, to make alterations and amendments therein, to receive the patent, and to transact all business in the Patent and Trademark Office connected therewith.

We request that all correspondence in respect to this application be directed to Harold V. Stotland, Seyfarth Shaw, 42nd Floor, 55 East Monroe Street, Chicago, Illinois 60603-5803, whose telephone number is 312-346-8000.

All statements made herein of our own knowledge are true, all statements made on information and belief are believed to be true and these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that willful false statements may jeopardize the validity of the application or any patent issuing thereon.

Dated: >003, 7.21	Chin Cheng Yomey [Signature]
	Chin Cheng Yang [Name Printed]
	No. 16, Li-Hsin Rd. Science-Based Industrial Park, Hsinchu, Taiwan 300, R.O.C.
	[Residence and Post Office Address]